	Application No.	Applicant(s)
Notice of Allowability	10/089,479	KIM, BONG-CHEOL
	Examin r	Art Unit
	David Nhu	2818
The MAILING DATE of this communication All claims being allowable, PROSECUTION ON THE MERIT herewith (or previously mailed), a Notice of Allowance (PTO NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATE of the Office or upon petition by the applicant. See 37 CFR	IS IS (OR REMAINS) CLOSED in L-85) or other appropriate common NT RIGHTS. This application is s	n this application. If not included
This communication is responsive to <u>10/7/03</u> . The allowed claim(s) is/are 18-23 The drawings filed on <u>28 March 2002</u> are accepted b Acknowledgment is made of a claim for foreign priorit a) All b) Some* c) None of the:		r (f).
 Certified copies of the priority documents 	have been received.	
Certified copies of the priority documents	have been received in Application	n No
 Copies of the certified copies of the priori International Bureau (PCT Rule 17.2(a 		d in this national stage application from the
Certified copies not received: Acknowledgment is made of a claim for domestic prio (a) The translation of the foreign language provisic Acknowledgment is made of a claim for domestic prio	onal application has been received	d.
Applicant has THREE MONTHS FROM THE "MAILING DAT below. Failure to timely comply will result in ABANDONMEN		
7. A SUBSTITUTE OATH OR DECLARATION must be INFORMAL PATENT APPLICATION (PTO-152) which gives		
8. CORRECTED DRAWINGS must be submitted. (a) including changes required by the Notice of Draft 1) hereto or 2) to Paper No	ving correction filed, which	th has been approved by the Examiner.
Identifying indicia such as the application number (see 37 Ceach sheet.	FR 1.84(c)) should be written on the	ne drawings in the front (not the back) of
DEPOSIT OF and/or INFORMATION about the cattached Examiner's comment regarding REQUIREMENT FOR THE PROPERTY OF THE PROPER	deposit of BIOLOGICAL MATE OR THE DEPOSIT OF BIOLOGI	ERIAL must be submitted. Note the CAL MATERIAL.
Attachment(s)		
1 ☐ Notice of References Cited (PTO-892) 3 ☐ Notice of Draftperson's Patent Drawing Review (PTO-94 5 ☐ Information Disclosure Statements (PTO-1449), Paper N 7 ☐ Examiner's Comment Regarding Requirement for Depot of Biological Material	8 4	f Informal Patent Application (PTO-152) Summary (PTO-413), Paper No "s' Amendment/Comment r's Statement of Reasons for Allowance
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EXAMINER'S AMENDMENT

Applicant's election of claims 18-23 in paper No. 4 is acknowledged. Because
 Applicant did not distinctly and specifically point out the supposed error in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)). Applicant have the right to file a divisional application covering the subject matter of the non-elected claims 1-17, 24.

The traversal is on the ground(s) that see the election paper. This is not found persuasive because the fields of search for method' and device claims are NOT coextensive and the determinations of patentability of method and device claims are different, that is process limitations and device limitations are given weight differently in determining the patentablitity of the claimed inventions. Also, the strategies for doing text searching of the device claims and method claims are different. Thus, separate searches are required.

The requirement is still deemed proper and is therefore made FINAL.

An examiner's amendment to the record appears below. Should the change and/or
additions be unaceptable to applicant, an amendment may be filed as provided by 37 CFR
1.312. To ensure consideration of such an amendment, it MUST be submitted no later than
the payment of the issue fee.

The application has been amended as follows:

Cancel claims 1-12, 17, 24.

REASONS FOR ALLOWANCE

3. Claims 18-23 are allowed.

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4. The following is an examiner's statement of reasons for allowance: None of the references

of record teaches or suggests as cited in claims 18: moving the parent substrate on which the

single crystalline nitride film is formed into a heating chamber that is connected to the reacting;

moving onto a support the parent substrate, wherein the supporter is positioned in the heating

chamber; heating the parent substrate up to a predetermined temperature which is higher than

a room temperature; and while the single crystalline nitride film is at about the predetermined

temperature that is higher than the room temperature, illuminating a laser beam on a backside

of the parent substrate and separating the single crystalline nitride film from the parent

substrate.

5. Any comments considered necessary by applicant must be submitted no later than the

payment of the issue fee and, to avoid processing delays, should preferably accompany the

issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons

for Allowance."

CONCLUSION

6. The prior art made of record and not relied upon is considered pertinent to applicant's

disclosure: Itoh et al (6,218,207 B1): Method for Growing Nitride Semiconductor Crystals,

Nitride Semiconductor Device, and Method for Fabricating the Same.

7. Any inquiry concerning this communication on earlier communications from the examiner

should be directed to David Nhu, (703) 306-5796. The examiner can normally be reached

on Monday-Friday from 7:30 AM to 5:00 PM.

The examiner's supervisor, David Nelms can be reached on (703) 308-4910.

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The fax phone number for the organization where this application or proceeding is assigned is (703) 308-872-9306.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-0956

San Da

David Nhu

October 31, 2003

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